MATERIALS LETTERS EDITORS NAMED

MRS appoints Associate Editors to new letters journal

As part of the Society's affiliation with the new journal, *Materials Letters*, it appoints a majority of Associate Editors to the journal's Editorial Board. (As the *Bulletin* has reported earlier, the two Principal Editors of the journal are among the MRS's leadership.) Some 28 members constitute the initial MRS representatives.

These scientists will serve staggered terms of two, three or four years, so that in the future a third of the Editorial Board will come up for appointment each year.

Potential contributors to *Materials Letters* are invited to submit contributions to Associate Editors, as well as the journal's Principal Editors.

The editors, their affiliation and area(s) of expertise are:

B.R. Appleton
Oak Ridge National Laboratory
Laser processing; ion-solid interactions

Alan E. Bell
IBM-San Jose
Laser annealing; thin film optics
L.A. Boatner
Oak Ridge National Laboratory
Nuclear waste disposal; crystal growth; EPR

L.L. Chang
IBM-Yorktown Heights
MBE; superlattice and heterostructures
James W. Corbett
SUNY-Albany
Defects in semiconductors

James C.C. Fan
MIT-Lincoln Lab
Semiconductor materials; devices; material processing
Prof. Seijiro Furukuwa
Tokyo Institute of Technology
Ion implantation; epitaxial growth; beam annealing

Dr. James F. Gibbons
Stanford
Ion implantation; laser annealing
B.C. Giessen
Northeastern U.
Rapid solidification rate processing; metallic glasses; alloy phases

Society appoints twenty-eight Associate Editors to Materials Letters

Dr. Carol M. Jantzen
Du Pont-Savannah
Nuclear waste corrosion management

Elton N. Kaufmann
U. Calif.-Livermore
Nuclear spectroscopic methods; ion beam analysis; surface modification of materials
Dr. Philipp H. Klein
Naval Research Lab
Halides; crystal growth; IR materials
Prof. Kamil Klier
Lehigh University
Characterization catalysts; catalysis

Werner Lutze
Hahn-Meitner-Institut
Nuclear waste forms and materials properties
Farrel W. Lytle
Boeing
EXAFS; structure of catalysts; amorphous materials

Prof. J.W. Mayer
Cornell University
Silicide formation; ion beam modification of materials; thin film reactions
P.A. Montana
West Virginia U.
Materials for coal processing; coal conversion (catalysis); metal clusters characterization
Prof. B.L. Mordike
Technische Uni. Clausthal
Rapid solidification; deformation; composite materials

J.C. Phillips
Bell Labs-Murray Hill
Theory of chemical bonding in solids; network glasses; amorphous semiconductors
S. Thomas Picraux
Sandia National Lab
Ion beam modification of materials; ion implantation

Prof. Della M. Roy
Penn State University
Cement and concrete; ceramic processing; nuclear waste management
George A. Rozgonyi
No. Carolina State U.
Semiconductor defects; device processing

F.W. Saris
Institute for Atomic and Molecular Physics
Modification and analysis of materials with beams of ions/photons
Frans Spaegen
Harvard
Phase transformations; metallic glasses
John A. Stone
Du Pont-Savannah
Nuclear waste management and disposal

Earl R. Thompson
United Technologies
Composite materials; superalloys; powder metallurgy

C.W. White
Oak Ridge National Lab
Laser annealing; ion implantation
William B. White
Penn State University
Crystal chemistry; ceramic processing; nuclear waste materials; infrared and raman spectroscopy

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